

# Application Bulletin



Of interest for:  
Trace analysis, environmental analysis

No. 147/1 e

## Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry

<b>Summary</b>	The metals Cd, Co, Cu, Fe, Ni, Pb and Zn are determined in the sub-ppb range (limit of detection 0.05 µg/L) by means of stripping voltammetry. The DP-ASV method is used for Cd, Cu, Pb and Zn whereas Co, Ni and Fe are determined by means of the DP-CSV method (dimethylglyoxime or catechol complexes).  Use of the VA Processor and the sample changer allows automatic determination of the above metal ions in one solution. The method has been specially developed for trace analysis in the manufacture of semiconductor chips based on silicon. It can naturally also be employed successfully in environmental analysis.
<b>Instruments</b>	► VA Processor 646 with VA Stand 647 and, depending on the degree of automation required, VA Sample Changer 675 and Multi-Dosimats 665.
<b>Reagents</b>	All reagents used must be of at least purity grade puriss. p.a.. The solution must be prepared with ultrapure water ( $\leq 0.1 \mu\text{S}/\text{cm}$ 20°C).  ► <b>Acetate buffer</b> $\text{pH} = 4.6$ with $c(\text{CH}_3\text{COOH}) = 2 \text{ mol/L}$ and $c(\text{NH}_3) = 1 \text{ mol/L}$ .  ► <b>Ammonium chloride buffer</b> 26 mL $w(\text{HCl}) = 0.32$ and 44 mL $w(\text{NH}_3) = 0.25$ are made up to 100 mL with ultrapure water.  ► <b>Catechol solution:</b> $c(\text{Catechol}) = 1 \text{ mol/L}$ Catechol (5.5 g) is dissolved in 50 mL oxygen-free ultrapure water under a stream of nitrogen. The solution must be tightly stoppered and stored in the dark. The stability of the solution varies between 1 day and up to 3 weeks, depending on the purity of the catechol. (Allow to stand 1 h before use.)  ► <b>Pipes Buffer:</b> $c(\text{Pipes}) = 1 \text{ mol/L}$ 1,4-bis(2-ethanesulfonic acid) piperazine (6.047 g) is mixed with 1 mL $w(\text{NaOH}) = 0.3$ and a little ultrapure water. After adjustment of the pH to 8.0 with $w(\text{NH}_3) = 0.25$ , the solution is made up to 20 mL with ultrapure water.  ► <b>Dimethylglyoxime in triethanolamine</b> Dimethylglyoxime (0.5 g) is mixed with 100 mL triethanolamine/ultrapure water (1:1) over a period of 1 h using a magnetic stirrer. The insoluble components are then filtered off using a fluted filter and the clear filtrate stored in a dark bottle.  ► <b>Standard solutions</b> Solutions weaker than $\rho(\text{Me}) = 100 \text{ mg/L}$ are stored in plastic bottles and should be prepared every week as follows: The concentrated standard solution is diluted with ultrapure water and acidified with 0.4 mL/100 mL conc. $\text{HNO}_3$ .

## Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry

<b>Sample preparation</b>	<ul style="list-style-type: none"> <li>▶ One drop <math>w(HF) = 0.4</math> (40%) is placed on the chip and evaporated by warming. A white, powdery residue is formed. This is dissolved in a drop of conc. nitric acid and rinsed into the polarographic vessel with ultrapure water. A blank is prepared using the same reagents.</li> </ul>																																																																																																																								
<b>Method setup</b>	<ul style="list-style-type: none"> <li>▶ The first step involves simultaneous determination of the metals Zn, Pb, Cd, and Cu at pH = 5.0 according to the DP-ASV method.</li> <li>▶ In the second step, iron is determined in the pipes buffer in the form of a catechol complex at pH = 7.0...7.2 using the DP-CSV method.</li> <li>▶ Finally, Co and Ni are determined as their dimethylglyoxime complexes in NH<sub>3</sub>/NH<sub>4</sub>Cl buffer at pH = 9.1.</li> </ul>																																																																																																																								
<b>Determination</b>	<ul style="list-style-type: none"> <li>▶ Acetate buffer (50 µL) is added to the sample solution and the pH adjusted to 5.0 with <math>w(NH_3) = 0.1</math>. Duplicate determinations of Zn, Cd, Pb and Cu each with two standard additions are now performed (PAGE 3, lines 1...10).</li> <li>▶ Catechol solution (100 µL) and pipes buffer (300 µL) are now added. Iron is also determined in a duplicate analysis with two standard additions (PAGE 3, lines 11...19). The pH value of the solution should be 7.0...7.2.</li> <li>▶ Finally, the pH value is adjusted to 9.1...9.2 by addition of 500 µL ammonium chloride buffer. After addition of 100 µL triethanolamine/dimethylglyoxime solution, duplicate determinations of Co and Ni each with two standard additions are performed (PAGE 3, lines 20...27). A determination requires approx. 100 min when in this form.</li> </ul> <p>▶ <b>Fig. 1</b> shows the operation sequence of the method on PAGE 3.</p> <table style="width: 100%; border-collapse: collapse;"> <thead> <tr> <th colspan="2" style="text-align: center;">Zn,Cd,Pb,Cu,Fe,III und Co im sub-ppb-Bereich NFL 1 EL.TYP MHE</th> <th style="text-align: right;">METHOD 4 PAGE 3</th> </tr> <tr> <th colspan="2"></th> <th style="text-align: right;">OPERATION SEQUENCE</th> </tr> </thead> <tbody> <tr> <td colspan="2" style="text-align: center;">OPERATIONS/PARAMETERS</td> <td style="text-align: center;">OPERATIONS/PARAMETERS</td> </tr> <tr> <td>1 PURGE ;STIR ;ADDL ; 300 s</td> <td></td> <td>8a U.EIND -210 mV</td> </tr> <tr> <td>2 PURGE ;STIR ; 30 s</td> <td></td> <td>8b U.STEP 4 mV</td> </tr> <tr> <td>3 BPURGE;(REP ) ; 10 s</td> <td></td> <td>SW.RATE 6.6 mV/ s</td> </tr> <tr> <td>4 HMDE ;STIR ;MEAS ; 120 s</td> <td></td> <td>9 SWP 3 ; 61 s</td> </tr> <tr> <td>4a M.MODE DPN 50 mV</td> <td></td> <td>9a U.EIND 200 mV</td> </tr> <tr> <td>4b T.STEP 600 ms</td> <td></td> <td>9b U.STEP 4 mV</td> </tr> <tr> <td>4c U.SET -1.109 V</td> <td></td> <td>SW.RATE 6.6 mV/ s</td> </tr> <tr> <td>5 OSTIR ; 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## Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry

**Determination  
(continued)**

► For automation with the sample changer, the following additional instruments are needed:  
Seven Dosimats with the solutions:

1. Dosimat for the standard addition of Zn, Cd, Pb and Cu
2. Dosimat for the standard addition of Fe
3. Dosimat for the standard addition of Co and Ni
4. Dosimat for the addition of catechol solution (brown glass)

The Dosimats 1...4 are controlled via PAGE 4 (2.665.0010).

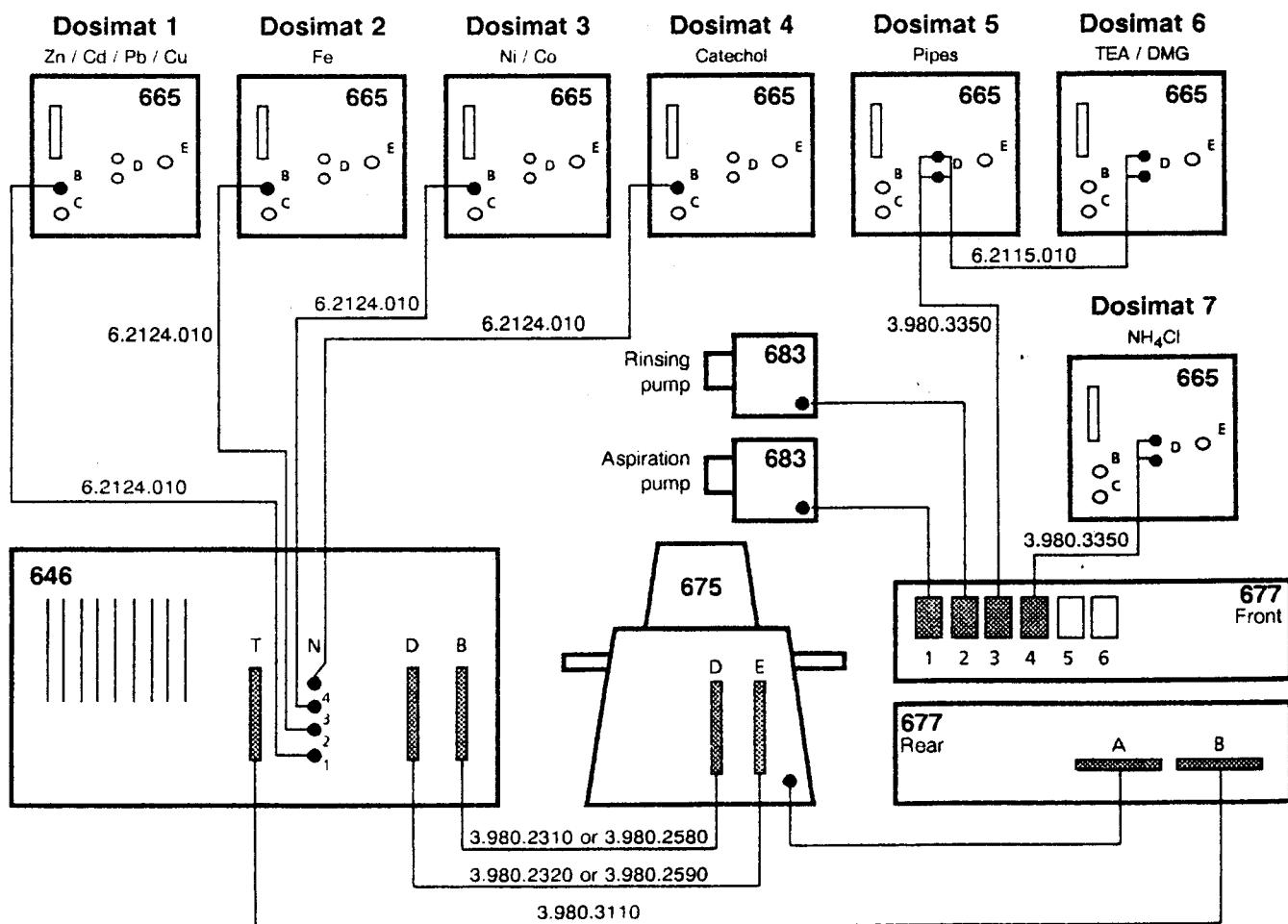
5. Dosimat for the addition of pipes buffer
6. Dosimat for the addition of triethanolamine/dimethylglyoxime
7. Dosimat for the addition of ammonium chloride buffer

The Dosimats 5...7 (as well as the two 683 Pump Units – siphoning and rinsing polarographic vessel/electrodes) are controlled via the 677 Drive Unit. The volume to be dispensed is stored in the burette and the addition triggered by a control pulse. Two special 3.980.3350 cables and one 6.2115.010 cable are needed for the connection to the 677 Drive Unit. The ammonium chloride and triethanolamine buffer solutions are controlled via a single cable and are thus both added at the same time.

► Additionally are needed:

- 3 × 6.182.010 Capillary tubing for the three auxiliary Dosimats
- 1 × A.403.009 Stopper  
(3 holes of Ø = 1.5 mm must be drilled by the customer).

**Fig. 2** Interconnection of the instruments with the cable connections



## Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry

**Illustrations**

The following Figures provide an overview of the determination of the 7 elements using the sample changer:

**Fig. 3 PAGE 2 of the 646 VA Processors.**  
Note particularly items 7...11.

Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler  
MPL 1 EL.TYP MME

METHOD 5 PAGE 2  
GEN.SPECIFICATIONS

## PARAMETERS

3 IR.MODE	N
4 SPEED	5
5 D.SIZE	7
6 N.DROPS	5

## RECOGNITION

7 SPIKE THRESH	5
8 H.THRESH	2
9 U.TOL	7
10 J.TOL	9
11 ASYM.TOL	8

**Fig. 4 PAGE 3, now completely filled for work with the sample changer (35 items)**

Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler  
MPL 1 EL.TYP MME

METHOD 5 PAGE 3  
OPERATION SEQUENCE

## OPERATIONS/PARAMETERS

1 PURGE ;STIR ;EADDL ;	30 s
2 PURGE ;STIR ;	60 s
3 @PURGE;REP ;	10 s
4 HMDE ;STIR ;MEAS ;	120 s
4a M.MODE DPN	50 mV
4b T.STEP	600 ms
4c U.SET	-1.109 V
5 @STIR ;	10 s
6 SWP 0 ;	53 s
6a U.END	-750 mV
6b U.STEP	4 mV
	SW.RATE
7 SWP 1 ;	45 s
7a U.END	-450 mV
7b U.STEP	4 mV
	SW.RATE
8 SWP 2 ;	36 s

## OPERATIONS/PARAMETERS

8a U.END	-210 mV
8b U.STEP	4 mV
	SW.RATE
9 SWP 3 ;	61 s
9a U.END	200 mV
9b U.STEP	4 mV
	SW.RATE
10 REP>1;BEEP ;ADD1 2;	
11 PURGE ;STIR ;DOS4 ;	120 s
12 CTRL 3;@CTRL3;PURGE ;	60.0 s
13 PURGE ;STIR ;EADDL ;	60 s
14 PURGE ;STIR ;	120 s
15 @PURGE;REP ;	10 s
16 HMDE ;STIR ;MEAS ;	120 s
16a M.MODE DPN	-50 mV
16b T.STEP	600 ms
16c U.SET	-250 mV

Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler  
MPL 1 EL.TYP MME

METHOD 5 PAGE 3  
OPERATION SEQUENCE

## OPERATIONS/PARAMETERS

17 @STIR ;	15 s
18 SUP 4 ;	60 s
18a U.END	-650 mV
18b U.STEP	4 mV
	SW.RATE
19 REP>1;BEEP ;ADD2 2;	
20 CTRL 4;@CTRL4;	20.0 s
21 PURGE ;STIR ;EADDL ;	120 s
22 PURGE ;STIR ;	120 s
23 @PURGE;REP ;	10 s
24 HMDE ;STIR ;MEAS ;	30 s
24a M.MODE DPN	-30 mV
24b T.STEP	600 ms
24c U.SET	-700 mV
25 @STIR ;MEAS ;	10 s
25a M.MODE DPN	-30 mV
25b T.STEP	600 ms

## OPERATIONS/PARAMETERS

25c U.SET	-800 mV
26 SWP 5 ;	63 s
26a U.END	-1.010 V
26b U.STEP	2 mV
	SW.RATE
27 SWP 6 ;	36 s
27a U.END	-1.250 V
27b U.STEP	4 mV
	SW.RATE
28 REP>1;BEEP ;ADD3 2;	
29 @MEAS ;STIR ;CTRL 1;	12.0 s
30 <REP>	
31 @CTRL1;CTRL 2;	20.0 s
32 @CTRL2;CTRL 1;REP>3;	40.0 s
33 @CTRL1;@STIR ;	
34 CHANGE;PURGE ;STIR ;	
35 BEEP ;END ;	

## Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry

**Illustrations  
(continued)**

**Fig. 5 PAGE 4.** Please note that minimum 80 µL are dispensed. Only burette cylinders of 1 mL and 5 mL should be employed.

Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler MPL 1 EL.TYPE MME				METHOD 5 PAGE 4 ALLOCATIONS	
a	b	c	d	e	f
SOLUTE	U.VERIF	DOS	V.SOLN	m.CONC	m.BLANK
Subst	Ux	Soln	c, v	rho.x	bx
1 Zn	-998 mV	1	c 80 µL	500.0 ug/L	0.000 g
2 Cd	-560 mV	1	c 80 µL	100.0 ug/L	0.000 g
3 Pb	-340 mV	1	c 80 µL	1.000 mg/L	0.000 g
4 Cu	30 mV	1	c 80 µL	100.0 ug/L	0.000 g
5 Fe	-450 mV	2	c 100 µL	500.0 ug/L	0.000 g
6 Ni	-934 mV	3	c 100 µL	1.000 mg/L	0.000 g
7 Co	-1.100 V	3	c 100 µL	40.00 ug/L	0.000 g
8 Catech		4	c 100 µL	110.0 g/L	0.000 g
9 SUPP.ELEC	c(HNO <sub>3</sub> )=0.01 mol/L				
10 V.MEAS	20.000 mL				
11 ALIQUOT	1.000				
12 DATE	87-01-12				
13 TIME	11:09				

**Fig. 6 PAGE 5**

Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler MPL 1 EL.TYPE MME				METHOD 5 PAGE 5 DATA OUTPUT	
a	b	c	d	e	
SEGMT	Y.AXIS/L	Y.AXIS/R	X.AXIS/DIV		
1 SWP 0	0.00 A	300 nA	100 mV		
2 SWP 1	0.00 A	25.0 nA	100 mV		
3 SWP 2	0.00 A	160 nA	100 mV		
4 SWP 3	0.00 A	160 nA	100 mV		
5 SWP 4	0.00 A	-160 nA	100 mV		
6 SWP 5	0.00 A	-400 nA	50.0 mV		
7 SWP 6	-6.00 nA	-20.0 nA	100 mV		
8					
9 RECORD	FR	SXXX			
10					
11 SEND					
12					

**Fig. 7 PAGE 6 with the calculation principles**

Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler MPL 1 EL.TYPE MME				METHOD 5 PAGE 6 RES.CALCULATION	
a	b	c	d		
ANALYTE	EVAL	R.QUANT	R.UNIT	SIGNIF.DIG	
1 Zn	N	rho(Zn)	ug/L	4	
2 Cd	N	rho(Cd)	ug/L	4	
3 Pb	N	rho(Pb)	ug/L	4	
4 Cu	N	rho(Cu)	ug/L	4	
5 Fe	N	rho(Fe)	ug/L	4	
6 Ni	N	rho(Ni)	ug/L	4	
7 Co	N	rho(Co)	ug/L	4	
8					
11 Zn	A	0.00000	1.00000 E+ 6	1.00000	
12 Cd	A	0.00000	1.00000 E+ 6	1.00000	
13 Pb	A	0.00000	1.00000 E+ 6	1.00000	
14 Cu	A	0.00000	1.00000 E+ 6	1.00000	
15 Fe	A	0.00000	1.00000 E+ 6	1.00000	
16 Ni	A	0.00000	1.00000 E+ 6	1.00000	
17 Co	A	0.00000	1.00000 E+ 6	1.00000	
18					
	(EV.QUANT + ADDEND)	* FACTOR	/ DIVISOR		

**Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry**

Illustrations  
(continued)

**Fig. 8 Result block of a blank value determination**

METROHM 646 VA-PROCESSOR (5.546.5041) Zn,Cd,Pb,Cu,Fe,Ni,Co mit Probenwechsler MPL 1 EL.TYPE MME							
SUPP.ELEC				METHOD 5			
V.MEAS				20.000 mL			
ALIQUOT				1.000			
REMARK Halbleiter - Analytik 7 Elemente in einer Methode; Blindw.HNO3 0.01m/L							
NAME	Wittmann						
RUN#	-1						
ANALYTE	L	R	S	U.SUBST	EV.VALUE		
Zn	A0	0	0	-962 mV	101.5 nA		
	A0	1	0	-966 mV	104.4 nA		
	A1	0	0	-966 mV	124.0 nA		
	A1	1	0	-966 mV	124.0 nA		
	A2	0	0	-966 mV	150.3 nA		
	A2	1	0	-966 mV	155.9 nA		
m.STD	40.00 ng		SLOPE 1.580 ug/uA		160.5 ng		
Cd	A0	0	1	-551 mV	1.792.4 pA		
	A0	1	1	-544 mV	1.816.3 pA		
	A1	0	1	-545 mV	7.575 nA		
	A1	1	1	-544 mV	3.525 nA		
	A2	0	1	-545 mV	6.649 nA		
	A2	1	1	-545 mV	6.898 nA		
m.STD	8.000 ng		SLOPE 2.680 ug/uA		1.947 ng		
Pb	A0	0	2	-351 mV	41.50 nA		
	A0	1	2	-352 mV	43.90 nA		
	A1	0	2	-351 mV	60.84 nA		
	A1	1	2	-351 mV	61.67 nA		
	A2	0	2	-351 mV	78.20 nA		
	A2	1	2	-351 mV	81.18 nA		
m.STD	80.00 ng		SLOPE 4.325 ug/uA		184.8 ng		
Cu	A0	0	3	15 mV	25.33 nA		
	A0	1	3	15 mV	27.07 nA		
	A1	0	3	7.3 mV	35.17 nA		
	A1	1	3	6.7 mV	34.64 nA		
	A2	0	3	6.7 mV	43.63 nA		
	A2	1	3	5.9 mV	44.21 nA		
m.STD	8.000 ng		SLOPE 982.7 ng/uA		23.69 ng		
Fe	A0	0	4	-451 mV	16.12 nA		
	A0	1	4	-454 mV	16.51 nA		
	A1	0	4	-451 mV	24.87 nA		
	A1	1	4	-452 mV	24.71 nA		
	A2	0	4	-445 mV	32.59 nA		
	A2	1	4	-446 mV	33.53 nA		
m.STD	50.00 ng		SLOPE 6.023 ug/uA		99.24 ng		
Ni	A0	0	5	-948 mV	105.3 nA		
	A0	1	5	-948 mV	109.5 nA		
	A1	0	5	-948 mV	114.3 nA		
	A1	1	5	-948 mV	137.3 nA		
	A2	0	5	-947 mV	136.3 nA		
	A2	1	5	-947 mV	159.7 nA		
m.STD	100.0 ng		SLOPE 4.923 ug/uA		526.3 ng		
Co	A0	0	6	-1.089 V	3.847 nA		
	A0	1	6	-1.089 V	3.464 nA		
	A1	0	6	-1.087 V	6.766 nA		
	A1	1	6	-1.087 V	8.159 nA		
	A2	0	6	-1.086 V	11.32 nA		
	A2	1	6	-1.085 V	13.43 nA		
m.STD	4.000 ng		SLOPE 876.3 ng/uA		2.751 ng		

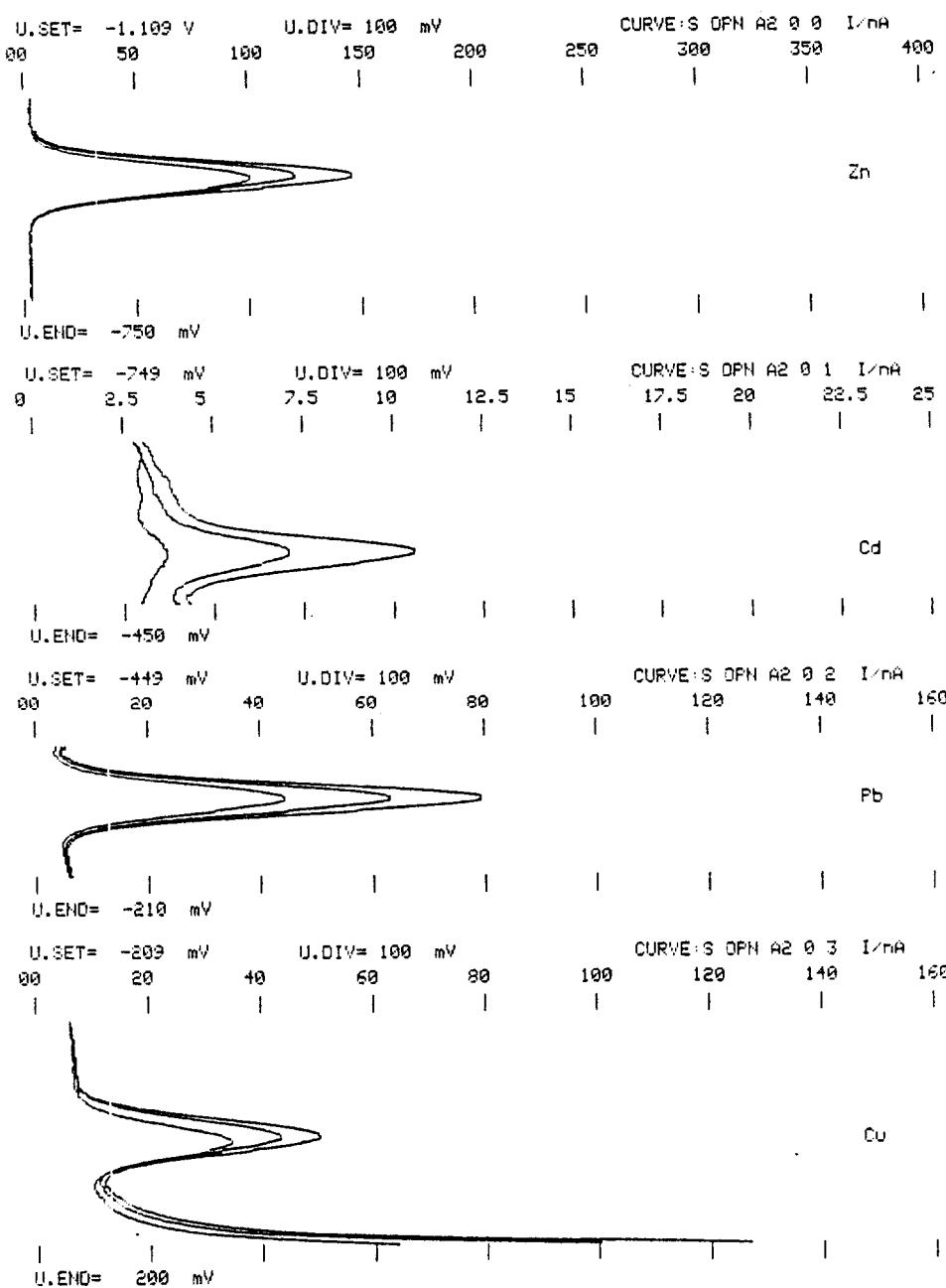
**Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry**

**Illustrations  
(continued)**

rho(Zn) =	8.029	ug/L
rho(Ni) =	-----	ug/L
rho(Co) =	-----	ug/L
rho(Cd) =	1.97.36 E- 3	ug/L
rho(Fe) =	-----	ug/L
rho(Pb) =	9.242	ug/L
rho(Cu) =	1.130	ug/L
rho(Cd) =	-----	ug/L
rho(Pb) =	-----	ug/L
rho(Fe) =	4.362	ug/L
rho(Zn) =	-----	ug/L
rho(Ni) =	26.31	ug/L
rho(Co) =	.1375	ug/L

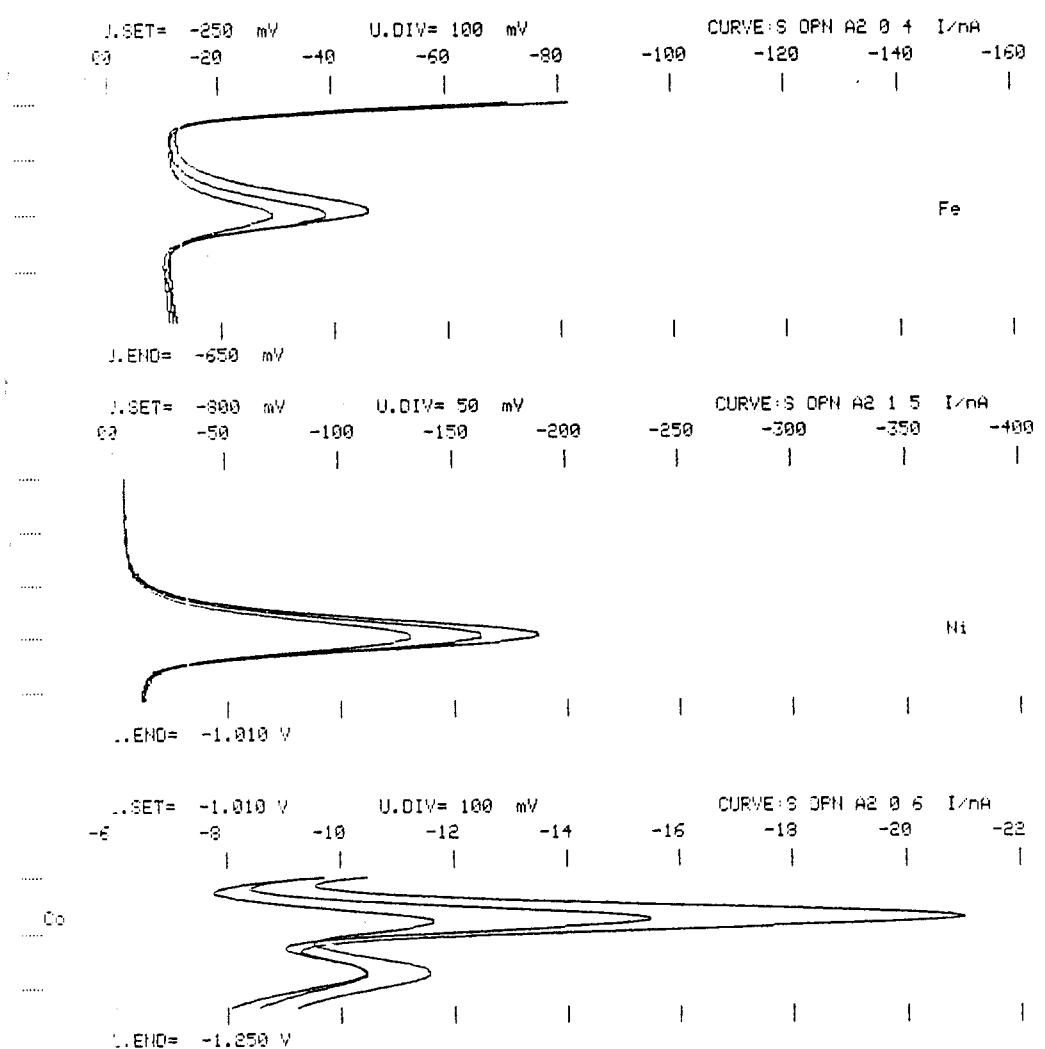
SMPL.V.m 20.0000 mL IDENT Test mit Probenw.  
DATE 87-01-09 TIME 12:37

**Fig. 9 Voltammograms for the data in Figure 8**



**Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry**

**Illustrations  
(continued)**



**Remarks**

- ▶ The electrodes and polarographic vessels are stored in  $w(HNO_3) = 0.08$  (8%) and also rinsed with this solution.
- ▶ The addition of triethanolamine increases the sensitivity of the Co determination. At the same time, it suppresses possible interferences due to relatively large Zn contents. The Ni peak is somewhat attenuated.
- ▶ In the standard additions, the peak potential of the iron-catechol complex is shifted slightly. This is due to the acidic standard addition solution. With this shift, which is dependent on pH, interferences caused by relatively large amounts of Cu can also be eliminated. (Cu also forms catechol complexes with peak potentials around -250 mV. For the iron complexes, the following dependences apply: pH = 6.9 -0.40 V // pH = 7.2: -0.45 V.)
- ▶ Pipes has a limited storage life. We found that the substance had decomposed after two years in a broached reagent bottle and was thus unfit for use. Pipes itself also shows a peak which moreover lies near that of the iron-catechol complex. Since this peak is small and flat, however, it can be subtracted as a blank value on PAGE 4 (e.g. 2 ng/20 mL). If buffer solutions are prepared using decomposed pipes, the base peak is steep and large. The blank value is increased by a factor 10 and makes evaluation of the iron impossible (Fig. 10 and 11).

**Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry**

Remarks  
(continued)

Fig. 10

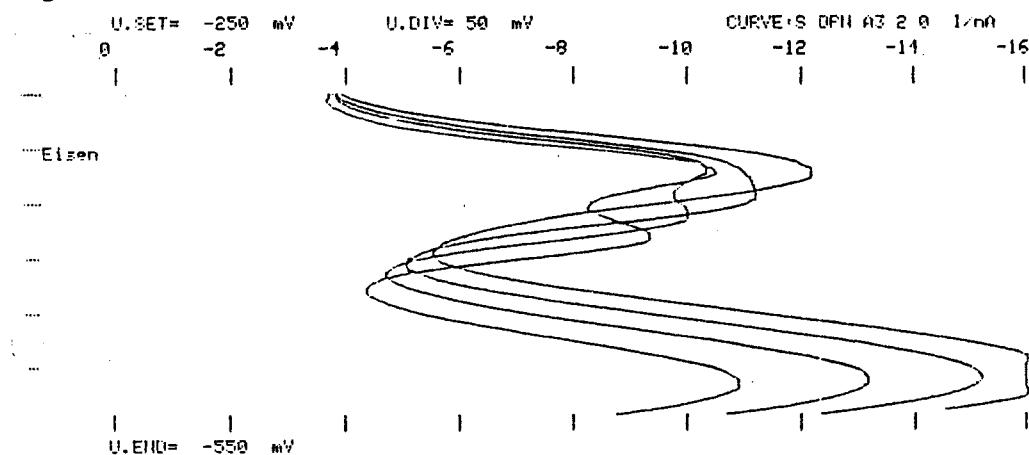
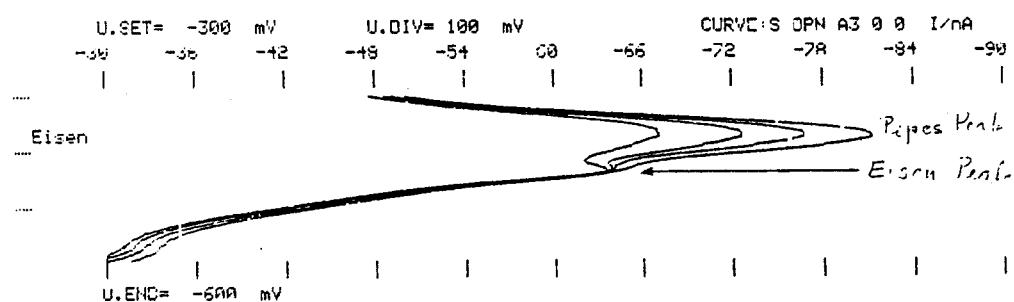
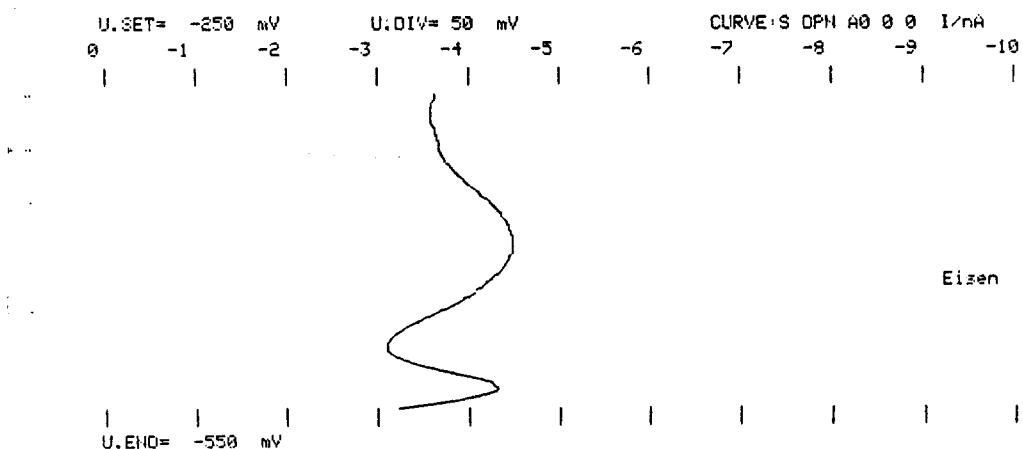


Fig. 11



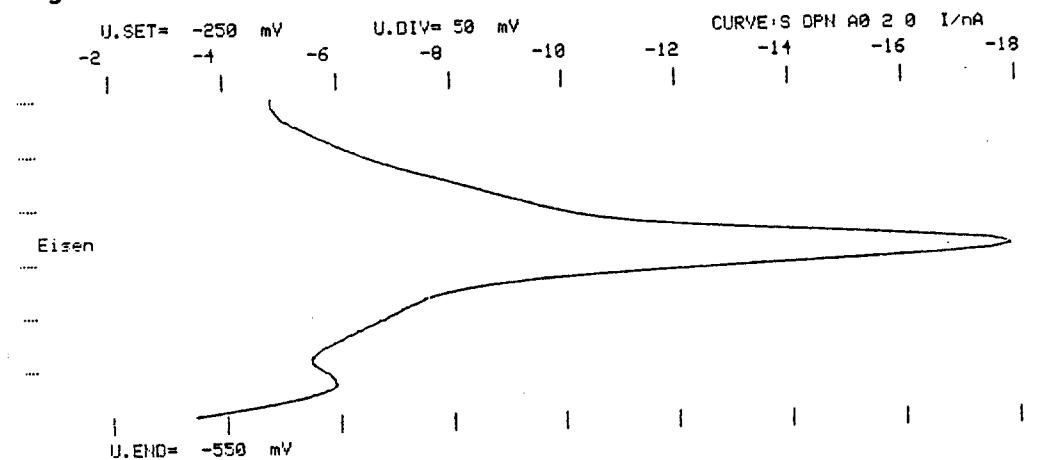
- The following method can be very useful to check the quality of the pipes:  
Pipes buffer (100  $\mu$ L) is added to 20 mL ultrapure water, the solution deaerated with nitrogen and a voltammogram recorded in the same manner as in the iron determination (without catechol addition). **Fig. 12** shows a good, **Fig. 13** a poor, decomposed pipes buffer.

Fig. 12



## Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry

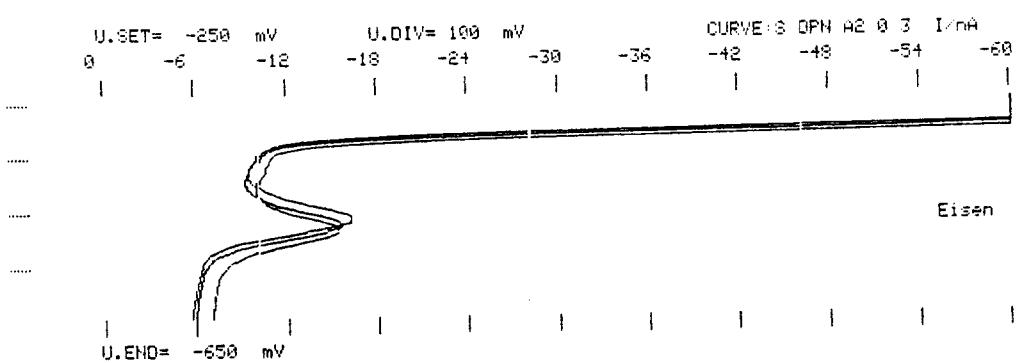
**Remarks**  
(continued)

**Fig. 13**

- ▶ The catechol solution should be prepared using pure, undecomposed catechol. If this solution has a brownish colour from the very start, filtration (fluted filter) is usually useful to enable the solution to be kept for 3...4 days.

Recrystallization from hot toluene followed by vacuum drying is better. Solutions prepared from catechol purified in this manner can be stored for up to 20 days.

Catechol solutions undergoing decomposition and which are thus unfit for use show the following behaviour: the peaks are shifted and become smaller. Furthermore, the standard additions are no longer linear and the baseline is highly distorted. **Fig. 14** shows an example of such a curve.

**Fig. 14**

**Simultaneous trace determination of 7 metal ions in "electronic grade" materials with the aid of stripping voltammetry****Literature**

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